

FORM PTO-1449/A and B (Modified) INFORMATION DISCLOSURE STATEMENT BY APPLICANT				APPLICATION NO.: <u>10/717,223</u>		ATTY. DOCKET NO.: S1022.80580US00			
				FILING DATE: November 19, 2003					
				APPLICANT: Richard Ferrant					
				GROUP ART UNIT: <u>2824</u>		EXAMINER: <u>TOAN LE</u>			
Sheet	1	of	1						

U.S. PATENT DOCUMENTS

Examiner's Initials #	Cite No.	U.S. Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication or of issue of Cited Document MM-DD-YY
		Number	Kind Code		
<u>TL</u>	*	5,331,588		Narahara	07/19/1994
<u>TL</u>	*	5,408,148		Pascucci et al.	04/18/1995
<u>TL</u>	*	4,651,305		Davis	03/17/1987

FOREIGN PATENT DOCUMENTS

Examiner's Initials #	Cite No.	Foreign Patent Document			Name of Patentee or Applicant of Cited Document (not necessary)	Date of Publication of Cited Document MM-DD-YY	Translation (Y/N)	
		Office/ Country	Number	Kind Code				

OTHER ART -- NON PATENT LITERATURE DOCUMENTS

Examiner's Initials #	Cite No	Include name of the author (in CAPITAL LETTERS) title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, relevant page(s), volume-issue number(s), publisher, city and/or country where published.	Translation (Y/N)
	*	International Search Report from patent application no. PCT/FR01/01608 filed May 23, 2001	
	*	Patent Abstracts of Japan, vol. 1995, no. 08, September 29, 1995 & JP 07 130165 A May 19, 1995	

EXAMINER <u>TOAN LE</u>	DATE CONSIDERED <u>5/17/05</u>
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#EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

*a copy of this reference is not provided as it was previously cited by or submitted to the office in a prior application, Serial No. 10/296,421, filed November 22, 2002, and relied upon for an earlier filing date under 35 U.S.C. 120 (continuation, continuation-in-part, and divisional applications).